

DATA SHEET - M-FRKLIFT

Wafer Lifting Device

Introduction

A typical application In the semiconductor industry is the handling of wafers. The wafer lift is an accessory which can be used with all magnetically driven dual shaft sample transporters. It allows for movement perpendicular to the transfer axis. The up/down movement is done with approximately half-turn in each direction of the outer magnet assembly of the sample transporter. Please contact us for a discussion about a customized interface for your specific wafer support.

Adds 2.0 to dimension Y of the main product

Wafer lifting device M-FRKLIFT	Description	Part Code
	Wafer lifting device	M-FRKLIFT

Specifications:

Materials

All UHV compatible

Vacuum Range

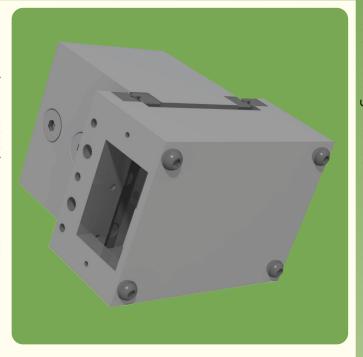
atm to 1x10⁻¹¹mbar

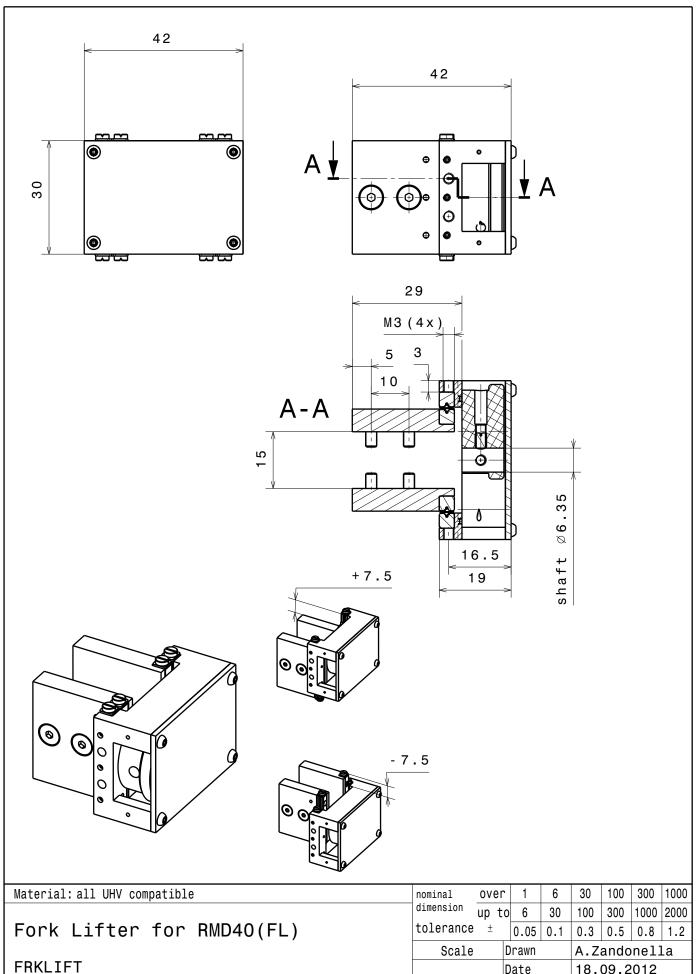
Bakeout Temperature *

200°C max.

Lift / Travel

+/- 7.5mm





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nominal OVE		er	1 6		30	100	300	1000
dimension	up	to	6	30	100	300	1000	2000
tolerance	<u>+</u>		0.05	0.1	0.3	0.5	0.8	1.2
Scale	Scale Drawn			A.Zandonella				
		D	ate		18.09.2012			
1 • 1		C	hange	ed	24.09.18 JB			
			FRKI TET					

LUVLIL sheet 1/2 Rev. D